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U.S. UTILITY PATENT APPLICATION

ML O.I.P.E. PATENT DATE
SCANNED 15 Q.A. Am

APPLICATION NO.	CONT/PRIOR	CLASS	SUBCLASS	ART UNIT	EXAMINERL
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Hee-Tae Lee Yoon-Sei Park Kwang-Sig Kim Jong-Woo Kim

Chemical vapor deposition process and apparatus for performing the same

PTO-2040 12/99

PREPARED AND APPROVED FOR ISSUE

ISSUING CLASSIFICATION								
ORI	GINAL		CR	OSS REFERENCE(S)		h.x	200	
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TERMINAL	DRAWINGS			CLAIMS ALLOWED		
☐ DISCLAIMER	Sheets Drwg.	Figs. Drwg.	Print Fig.	Total Claims	Print Claim for O.G.	
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subsequent to (date) has been disclaimed.	(Assistant Examiner) (Date)					
b) The term of this patent shall						
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